

FORM PTO-1449	U.S. Department of Commerce Patent and Trademark Office	Atty. Docket No. P29884	Application No. 10/577,305
<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b> (Use several sheets if necessary)		Applicant Dieter LEHMANN et al.	
		I.A. Filing Date October 22, 2004	Group Unknown

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	C L A S S	SUBCLASS	FILING DATE IF APPROPRIATE
/S.B./	5 5 7 6 1 0 6	11/19/96	KERBOW et al.			
/S.B./	4 <sup>36</sup> 5 1 3 0	05/24/83	MOLINSKI et al.			
/S.B./	3 2 9 8 9 4 2	05/20/98	MAGAT et al.			
/S.B./	6 3 8 7 9 6 4	05/14/02	D'AGOSTINO et al.			
/S.B./	6 2 2 5 3 6 8	05/01/01	D'AGOSTINO et al.			
/S.B./	5 7 5 6 1 9 9	05/26/98	KERBOW et al.			
/S.B./	6 7 7 0 3 7 8	08/03/04	LEHMANN			

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLAS S	SUBCLASS	TRANSLATION YES NO
/S.B./	1 5 1 6 6 4 8	07/05/78	GREAT BRITAIN			
/S.B./	9 6 / 0 3 4 4 8	02/08/96	W.I.P.O.			
	<del>1 4 6 7 1 6</del>	<del>10/22/79</del>	<del>GERMANY</del>			
/S.B./	2 3 1 8 8 9 6	02/18/77	FRANCE			
/S.B./	2004 - 1 0 7 4 6 1	04/08/04	JAPAN			
/S.B./	1 9 8 2 3 6 0 9	12/02/99	GERMANY			
/S.B./	9 9 / 6 1 5 2 7	12/02/99	W.I.P.O.			
/S.B./	63 - 0 0 7 4 5 5	01/13/88	JAPAN			
	<del>2 4 8 4 7 0 2</del>	<del>05/28/82</del>	<del>FRANCE</del>			

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/S.B./	1	A. Heger et al., Technologie der Strahlenchemie an Polymeren, Akademie-Verlag Berlin 1990, 463-488 and 496-501.
/S.B./	2	Ferse et al., Plaste u. Kautschuk, 29 (1982), 45-465.
/S.B./	3	K. Schierholz et al., J. Polym. Sci. Part B, Polymer Physics, Vol. 37, 2404-2411 (1999).
/S.B./	4	English Language Abstract of FR 2318896.
/S.B./	5	English Language Abstract of JP 2004-107461.
/S.B./	6	Dargaville et al., "High Energy Radiation Grafting Of Fluoropolymers", Prog. Poly. Sci. 28 (2003) 1355-1376.
/S.B./	7	English Language Abstract of JP 63-007455.
/S.B./	8	Patent Abstracts of Japan, Vol. 011, No. 222 (C-435), July 18, 1987
/S.B./	9	Patent Abstracts of Japan, Vol. 2003, No. 03, May 5, 2003
/S.B./	10	Patent Abstracts of Japan, Vol. 014, No. 252 (E-0934), May 20, 1990

EXAMINER	/Susan Berman/	DATE CONSIDERED	01/16/2009
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